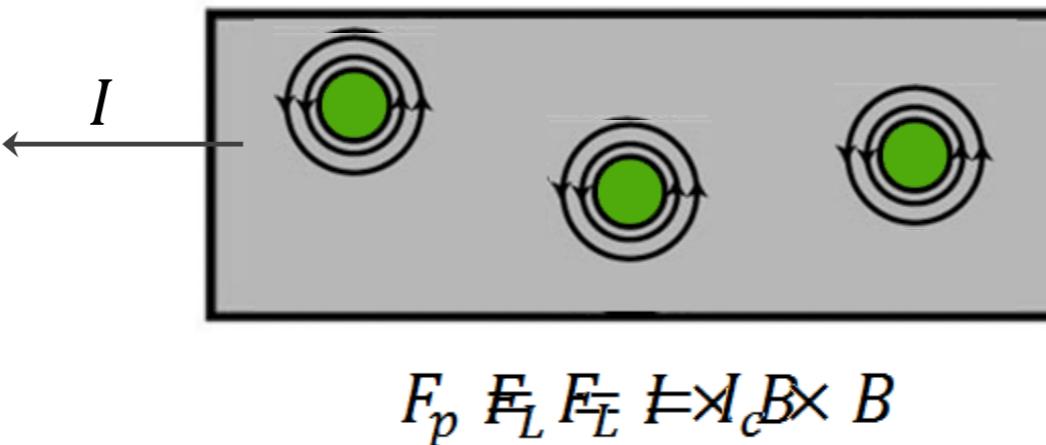
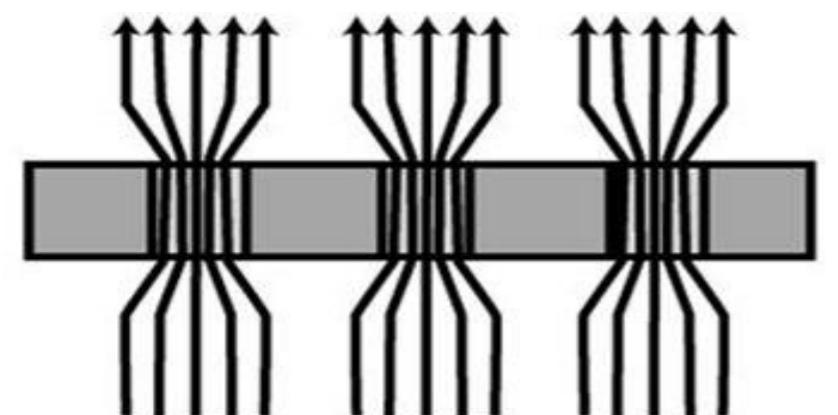


PROGRESS TOWARDS $\text{YBa}_2\text{Cu}_3\text{O}_{7-\delta}$ NANOCOMPOSITE THIN FILMS USING CHEMICAL SOLUTION DEPOSITION AND PREFORMED NANOCRYSTALS

Katrien De Keukeleere

H. Rijckaert, J. Hänisch, P. Cayado, A. Meledin, M. Sieger, F. Valles, M. Coll, A. Palau, J. Sierra, P. López-Domínguez, R. Hühne, J. De Roo, R. Hühne, G. Van Tendeloo, P. Paturi, H. Huhtinen, T. Puig, X. Obradors ,M. Hemgesberg, M. Bäcker, and I. Van Driessche

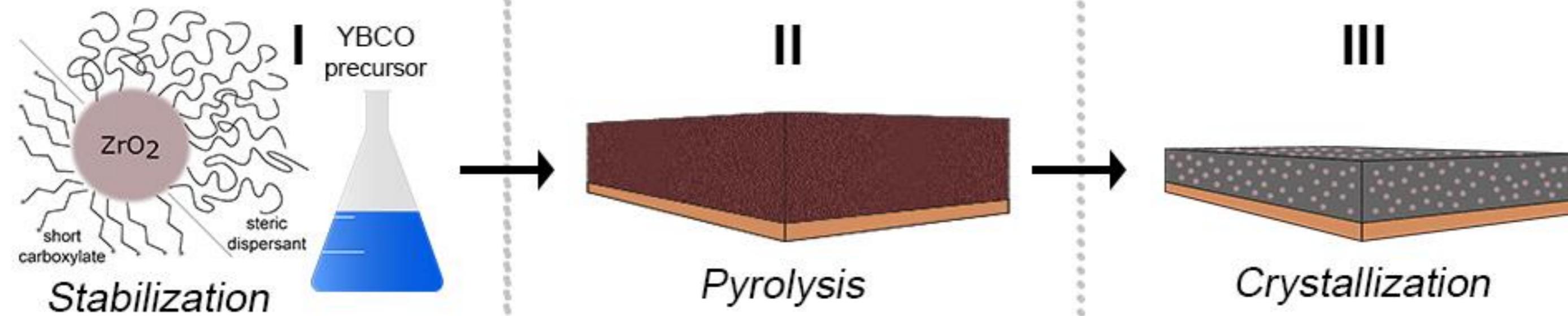
Vortex pinning



*Lorentz force
Movement of vortices
Energy dissipation*

*Pinning force =Lorentz force
Pinning of vortices*

CSD approach

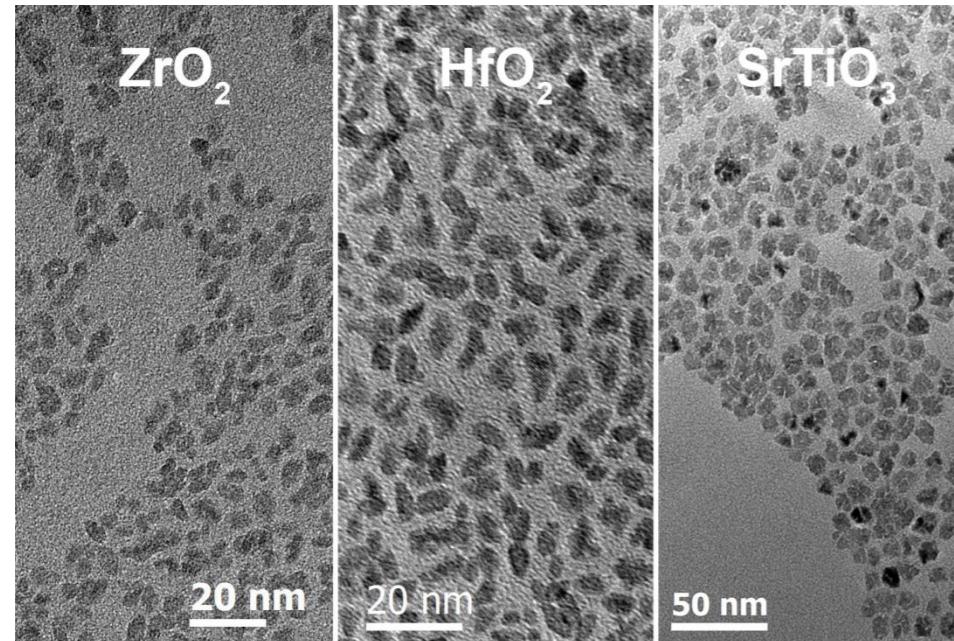


PREFORMED NANOCRYSTALS

Nanocrystal synthesis

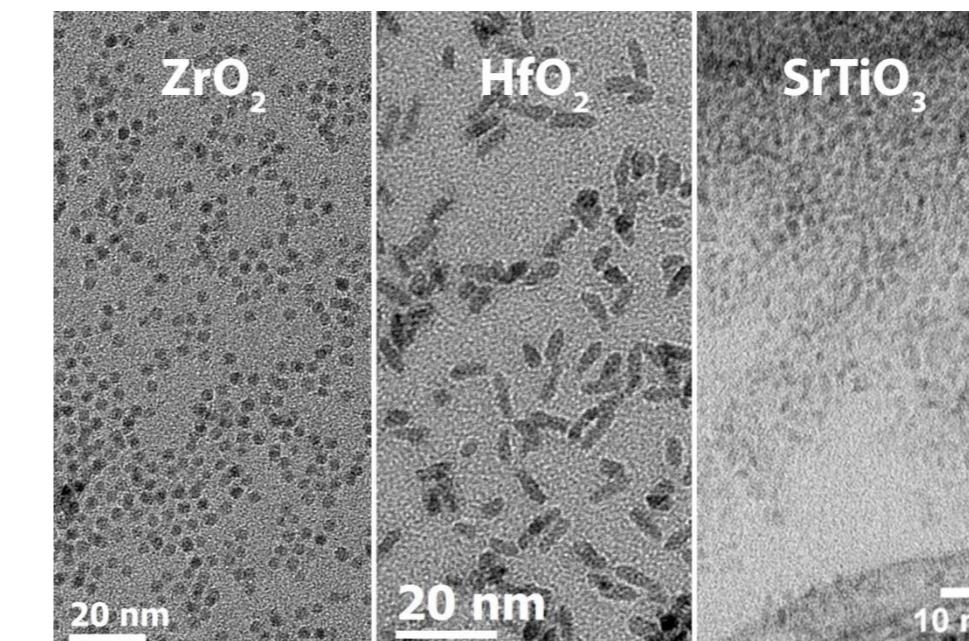
Microwave synthesis

Metal alkoxide in benzyl alcohol



Heating-up synthesis

Metal alkoxide in tri-n-octylphosphine oxide

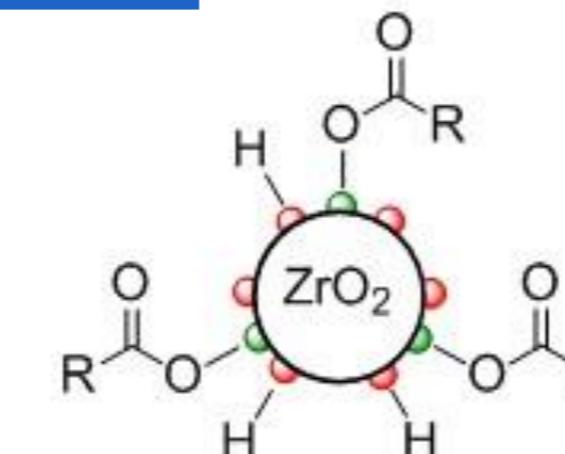


Goal:

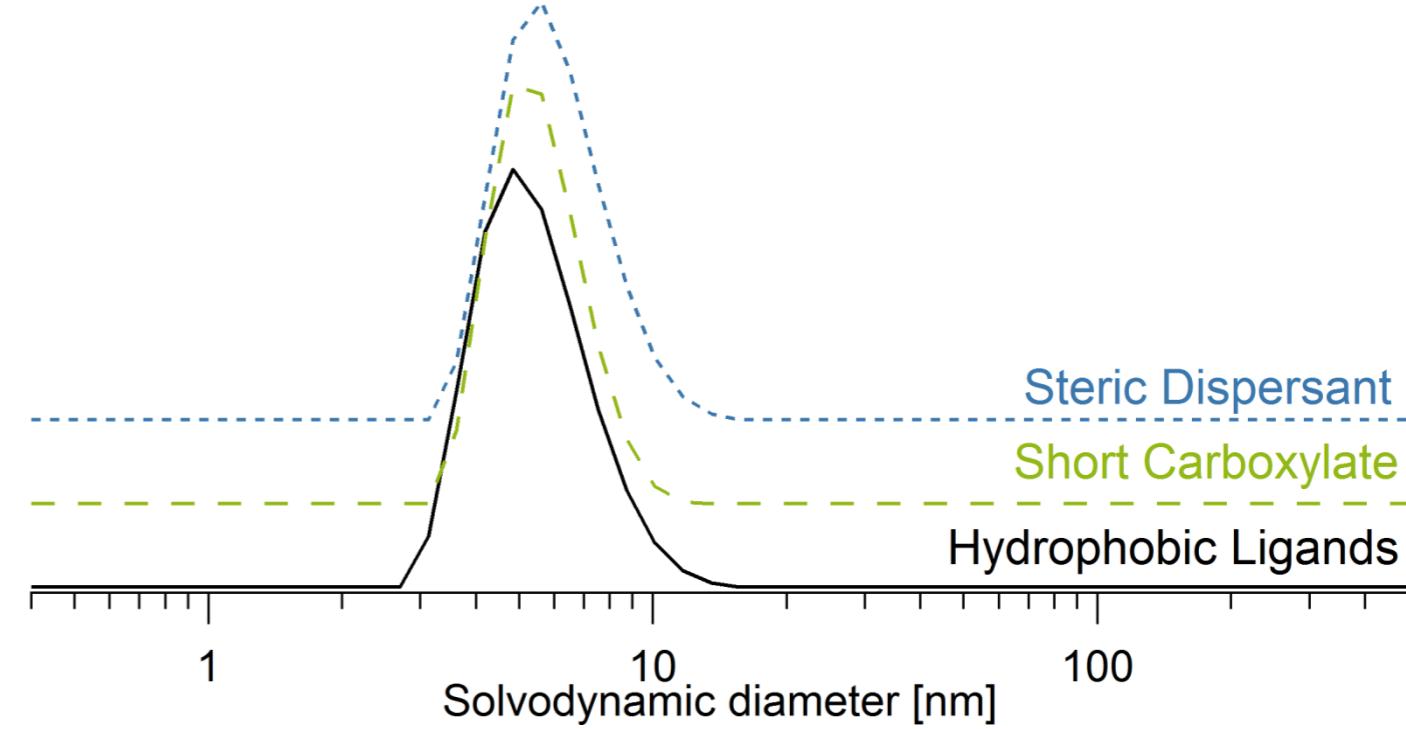
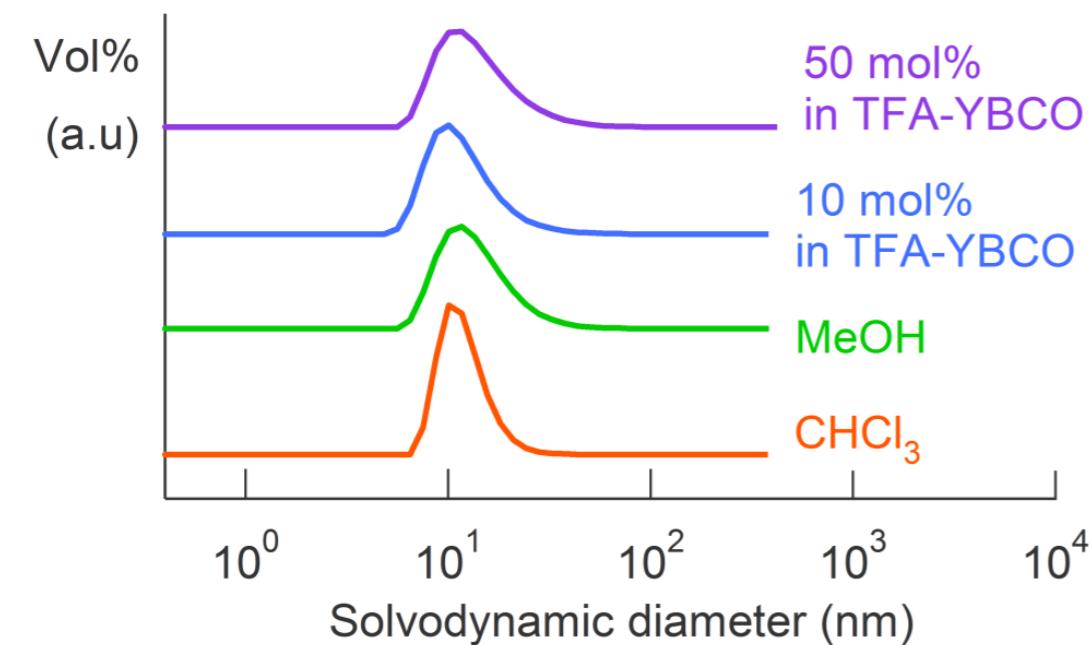
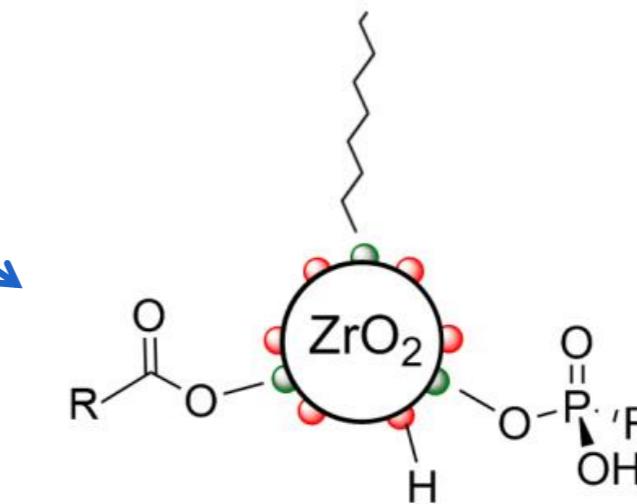
- Crystalline material
- Particle size: 3-10 nm
- Individual particles, free from agglomeration
- Stable in different solvents and YBCO

Nanocrystal stabilization

Charge and steric stabilization
via amino acid

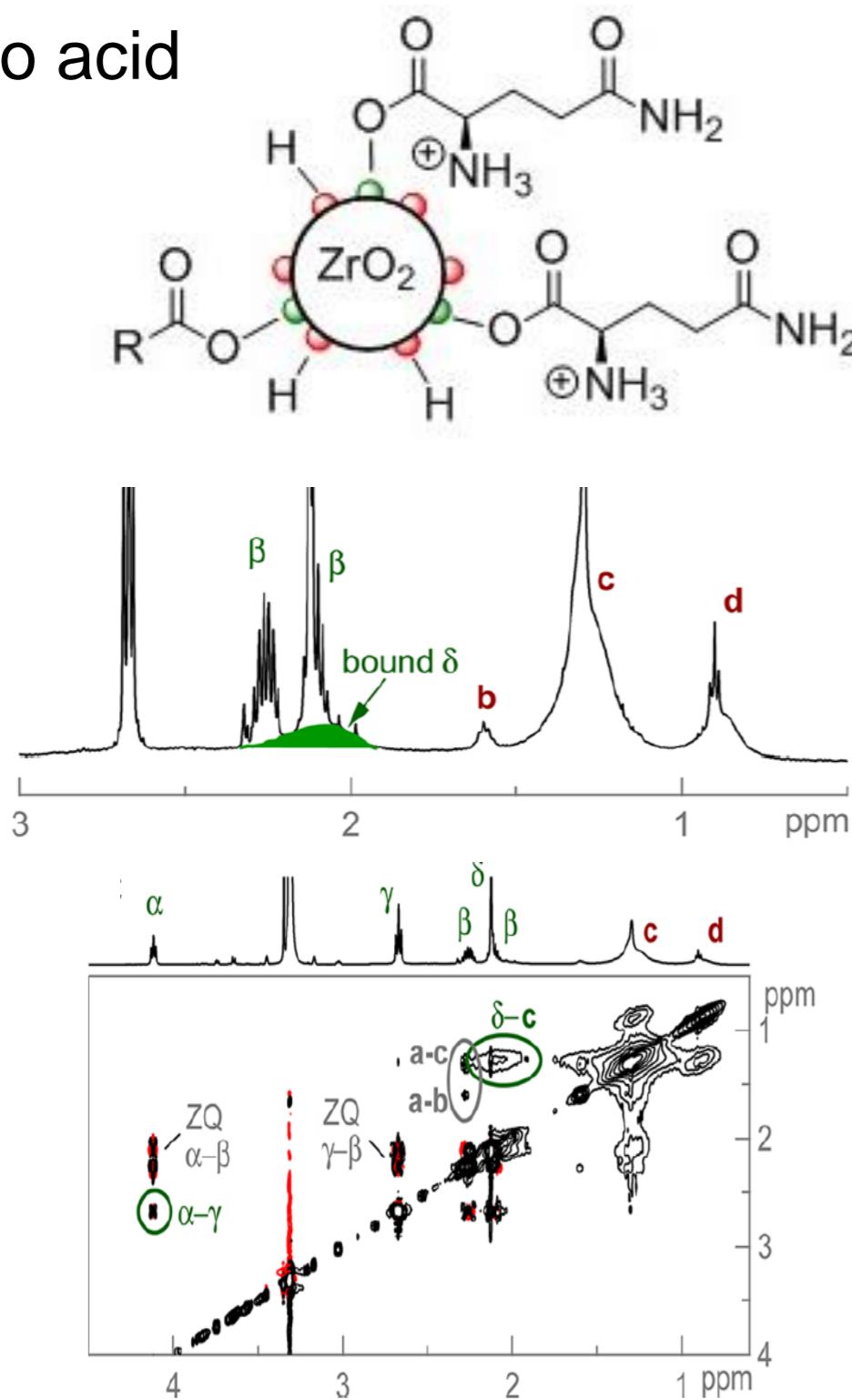


Steric stabilization
via short carboxylate or steric dispersant

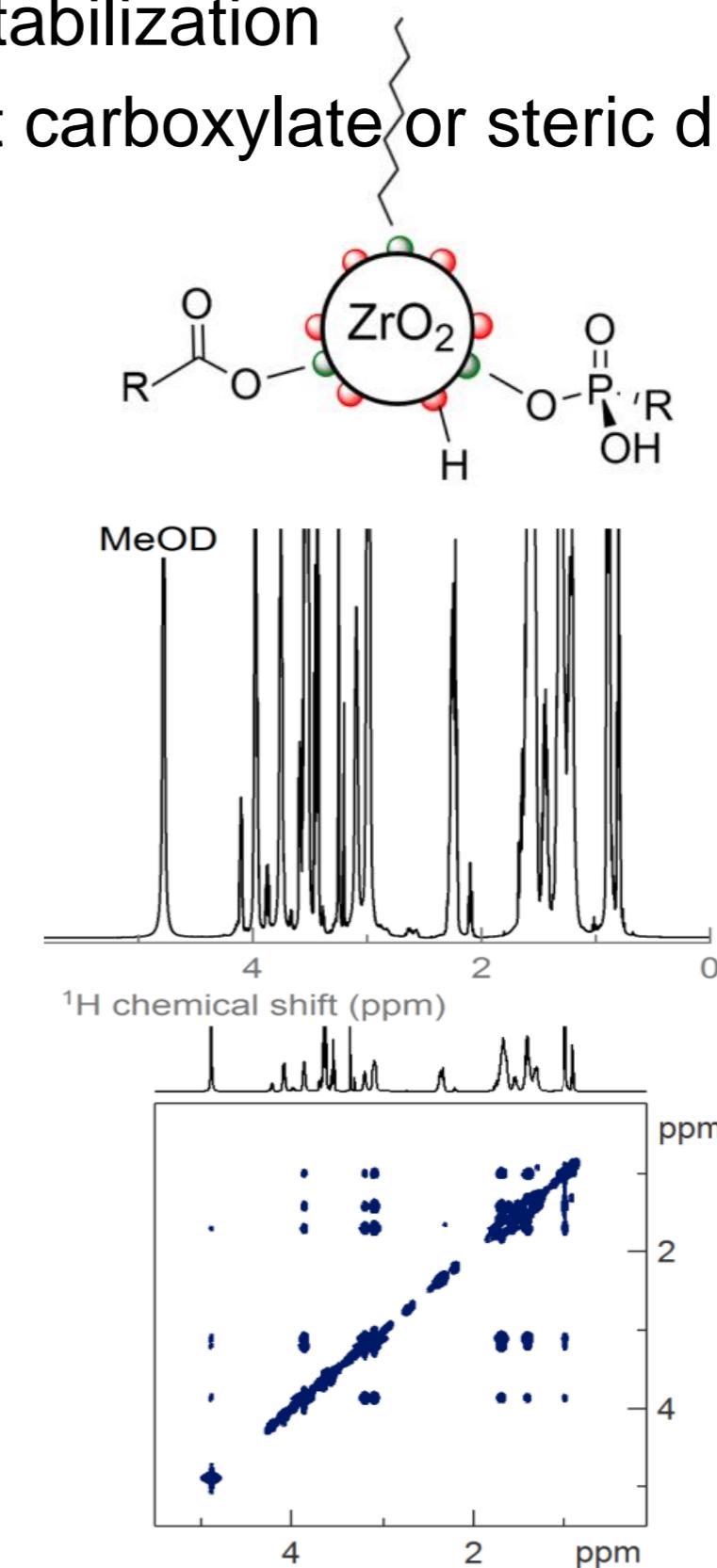


Nanocrystal stabilization

Charge and steric stabilization
via amino acid

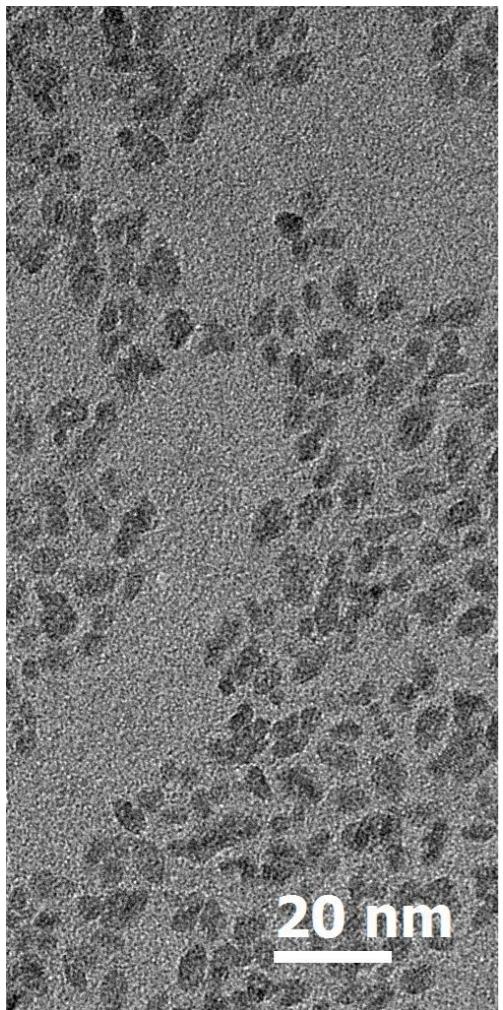


Steric stabilization
via short carboxylate or steric dispersant



TFA-BASED NANOCOMPOSITE

TFA-based nanocomposite

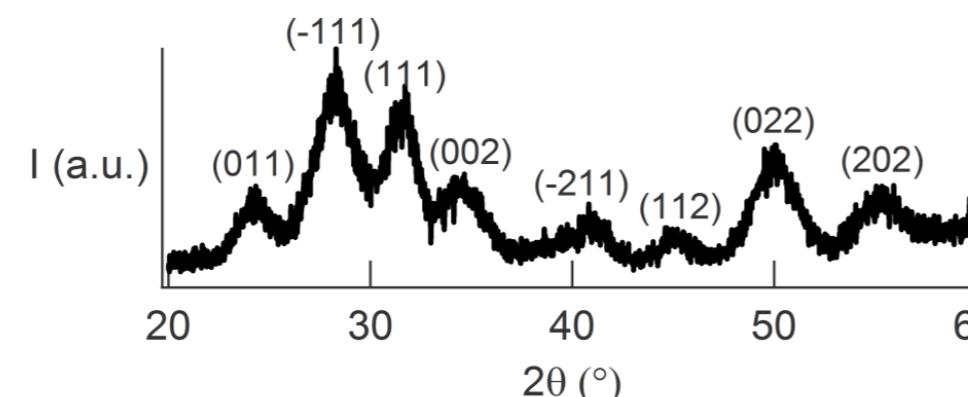


**ZrO₂
nanocrystals**

Microwave synthesis

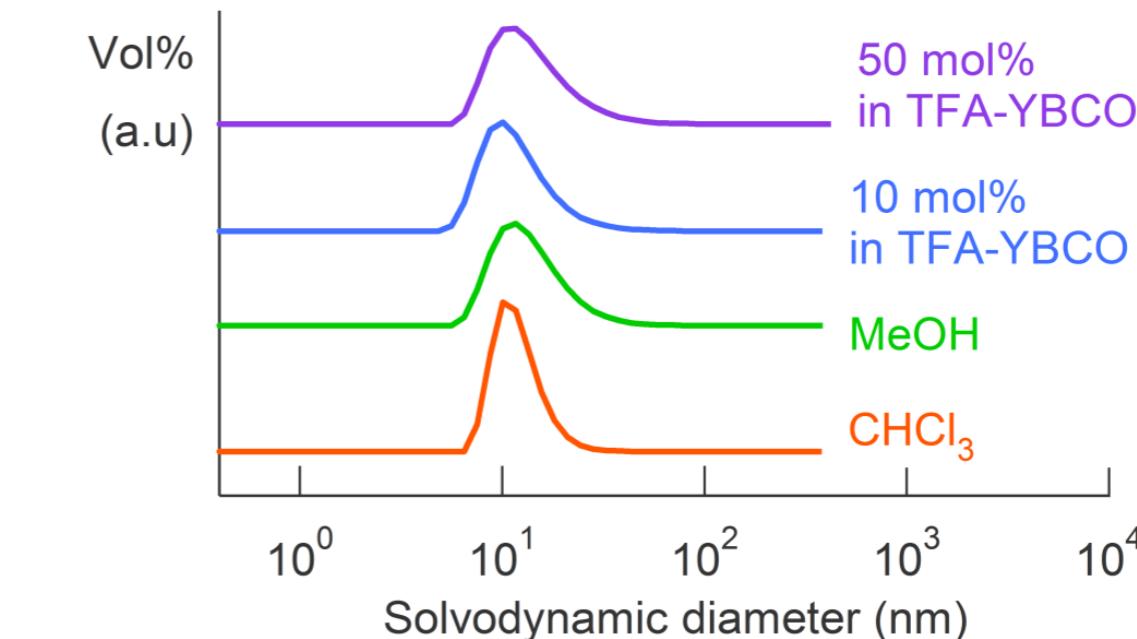
ZrCl₄ in benzyl alcohol
220 °C – 4h

TEM = 7 nm
DLS = 11 nm
XRD = 6 nm
Phase = monoclinic
Rietveld = 70%



Ligand Exchange/Phase transfer

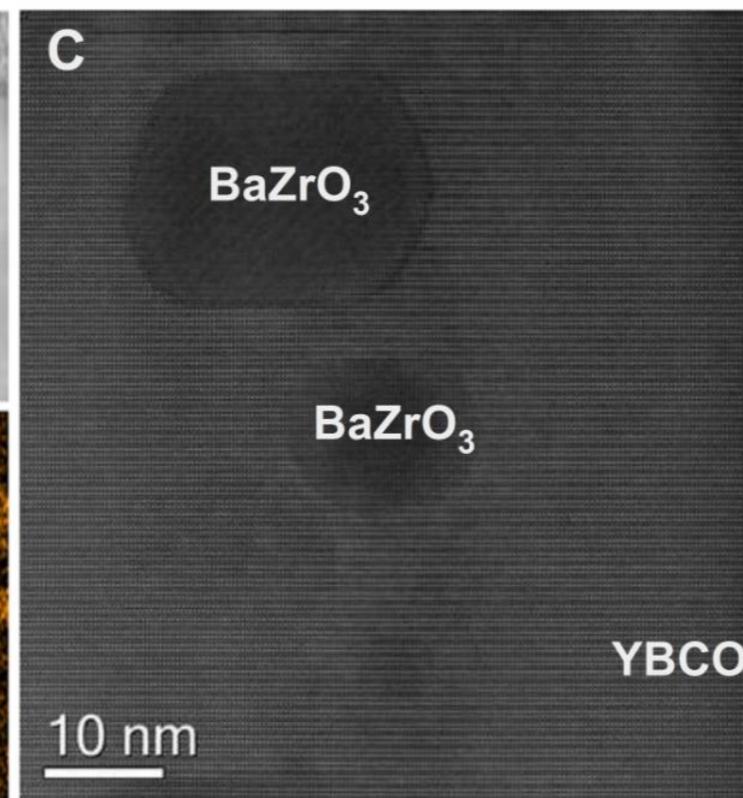
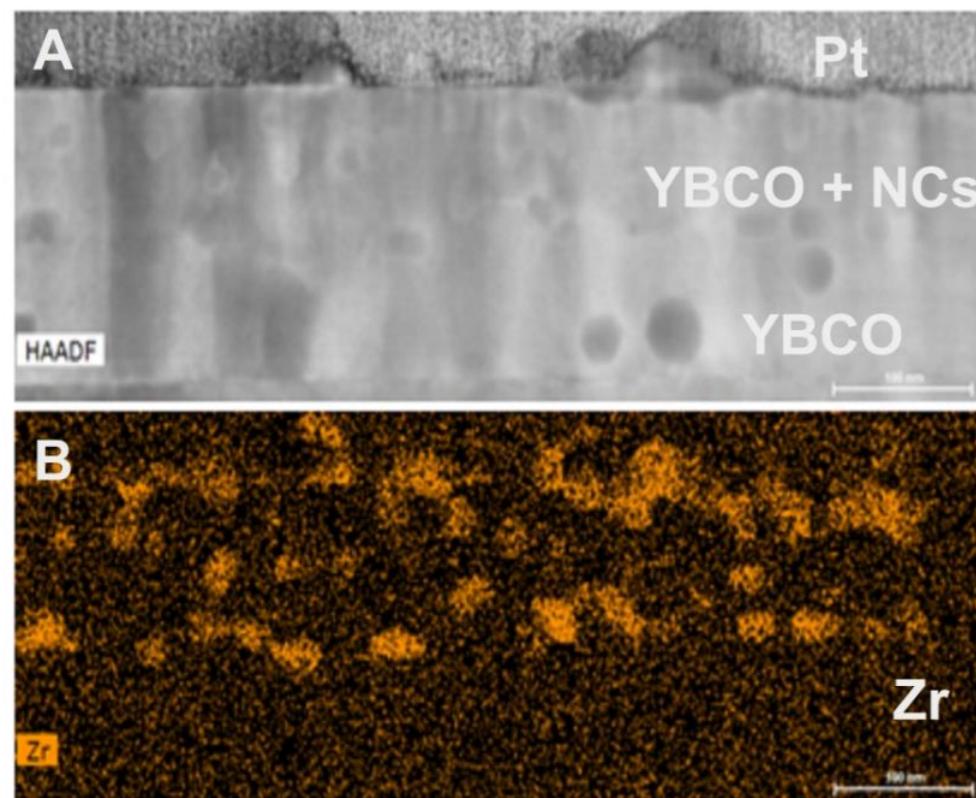
Via glutamine and TFA



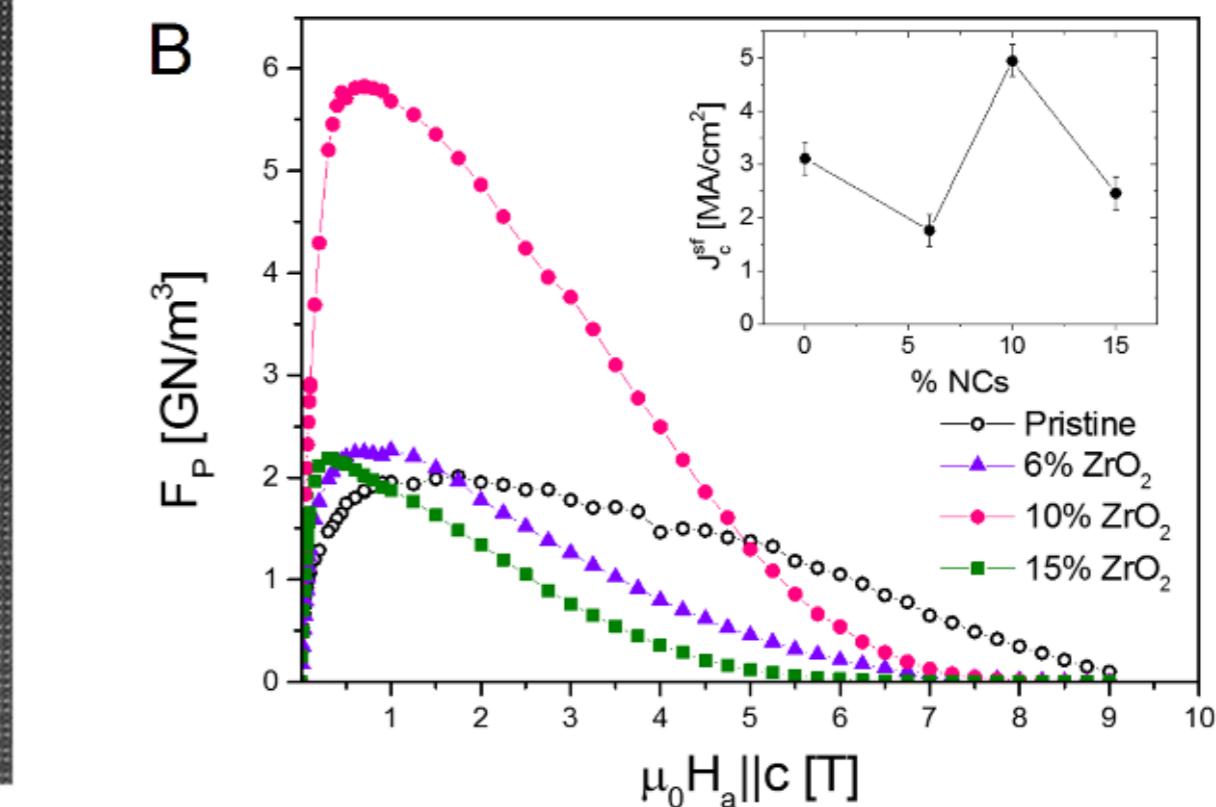
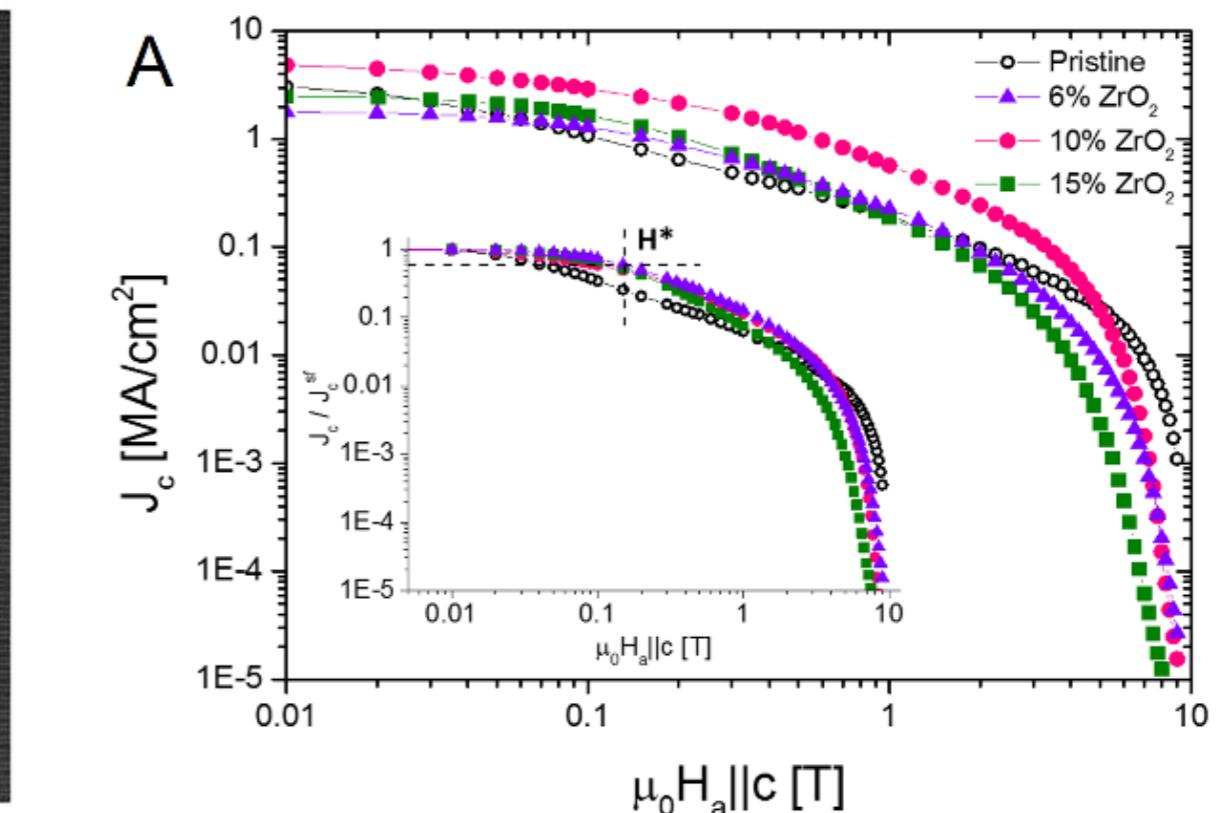
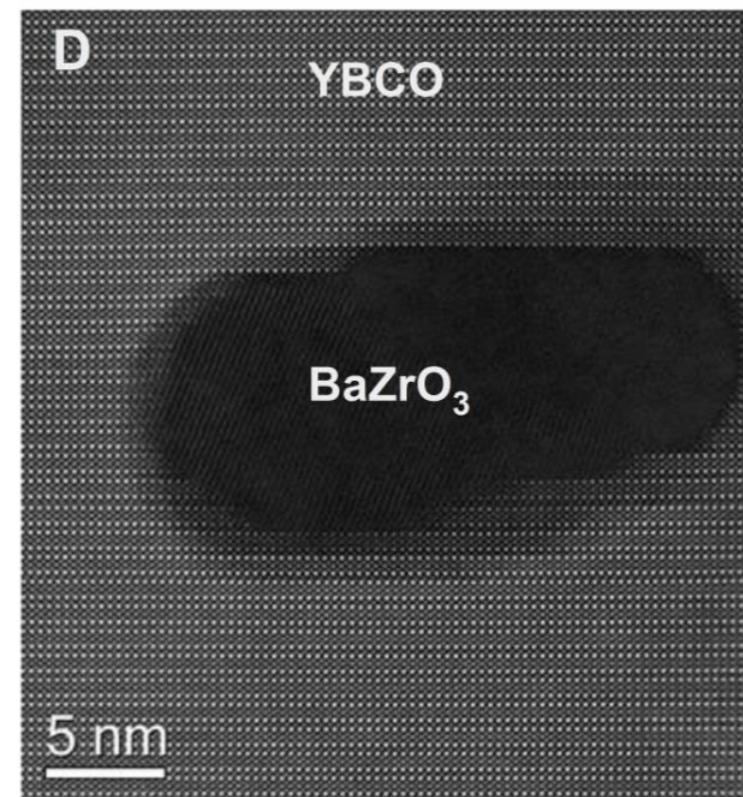
J. De Roo et al.; Langmuir. (2016) 32; 1962

K. De Keukeleere et al., Inorg. Chem. (2015) 54, 3469

TFA-based nanocomposite



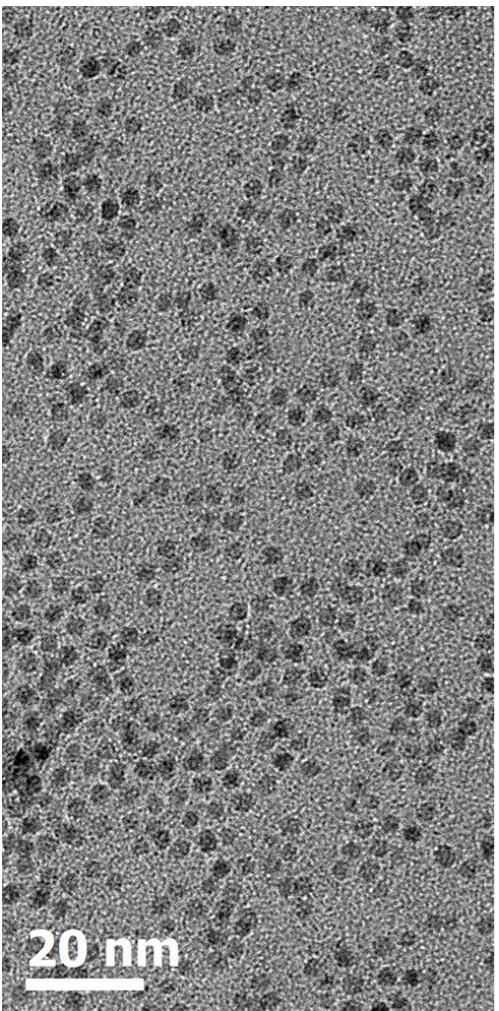
Zr- phase present throughout the YBCO layer
Some growth/agglomeration occurs
Small amount of stacking faults



LOW FLUORINE-BASED NANOCOMPOSITE

Low-fluorine nanocomposite

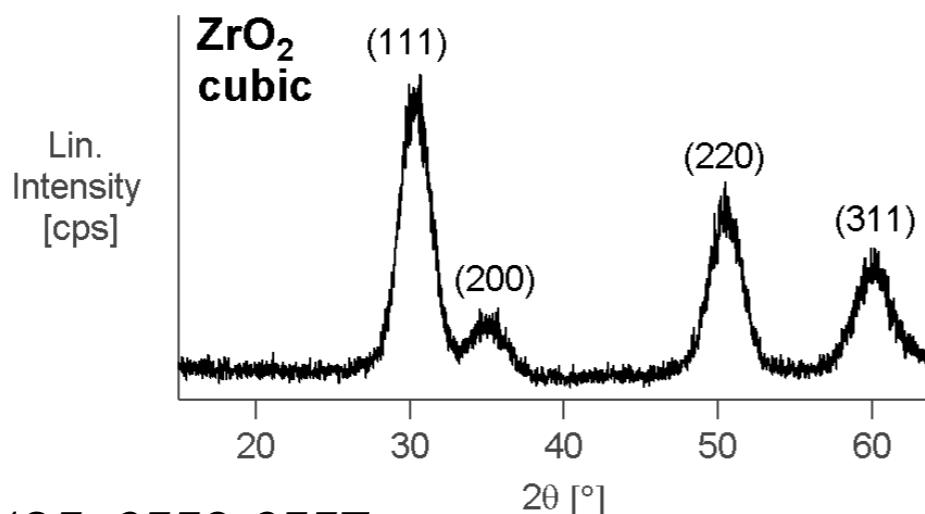
**ZrO₂
nanocrystals**



Heating up synthesis

Zr(OC₃H₇)₄, ZrCl₄ and TOPO
340 °C – 2h

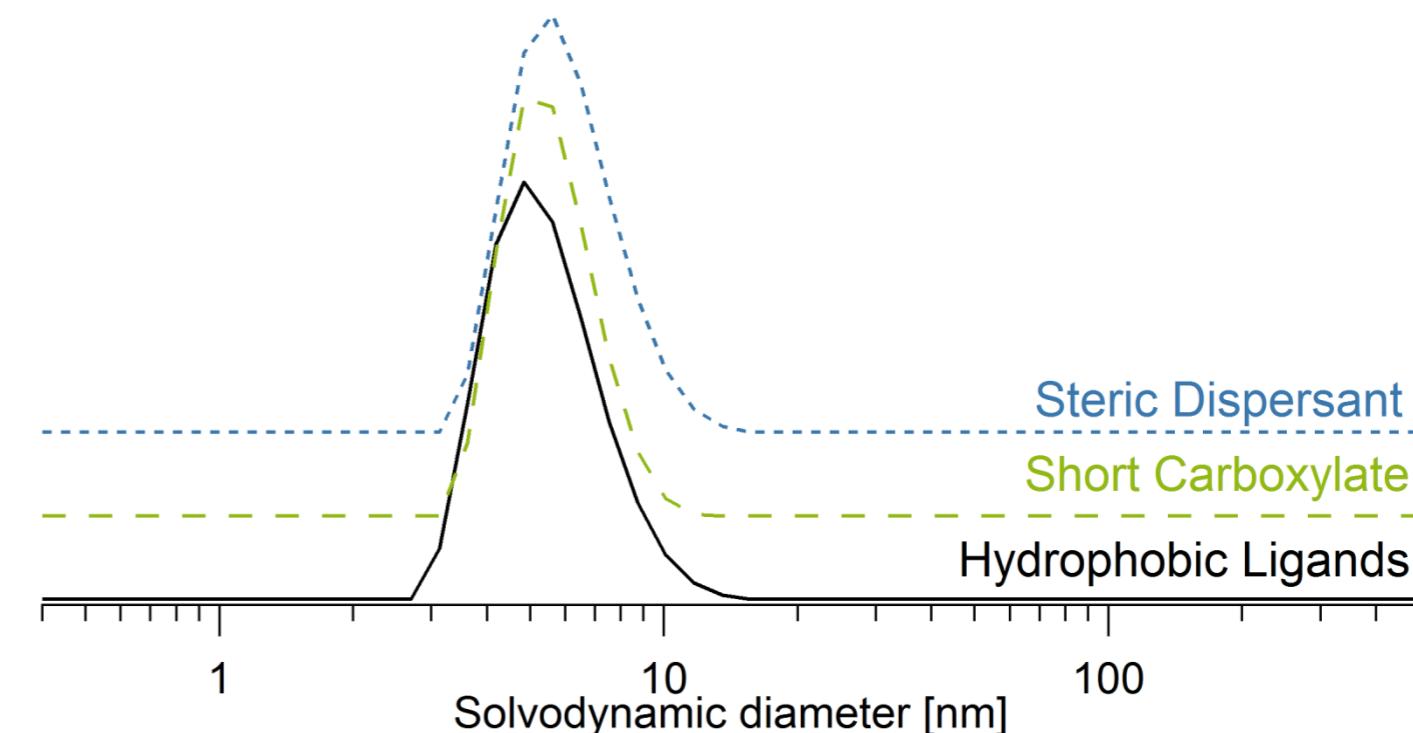
TEM = 3.5 nm
DLS = 6.4 nm
Scherrer = 3.5 nm
Phase = cubic
Rietveld = 80 %



J. Joo et al., JACS (2003) 125, 6553-6557

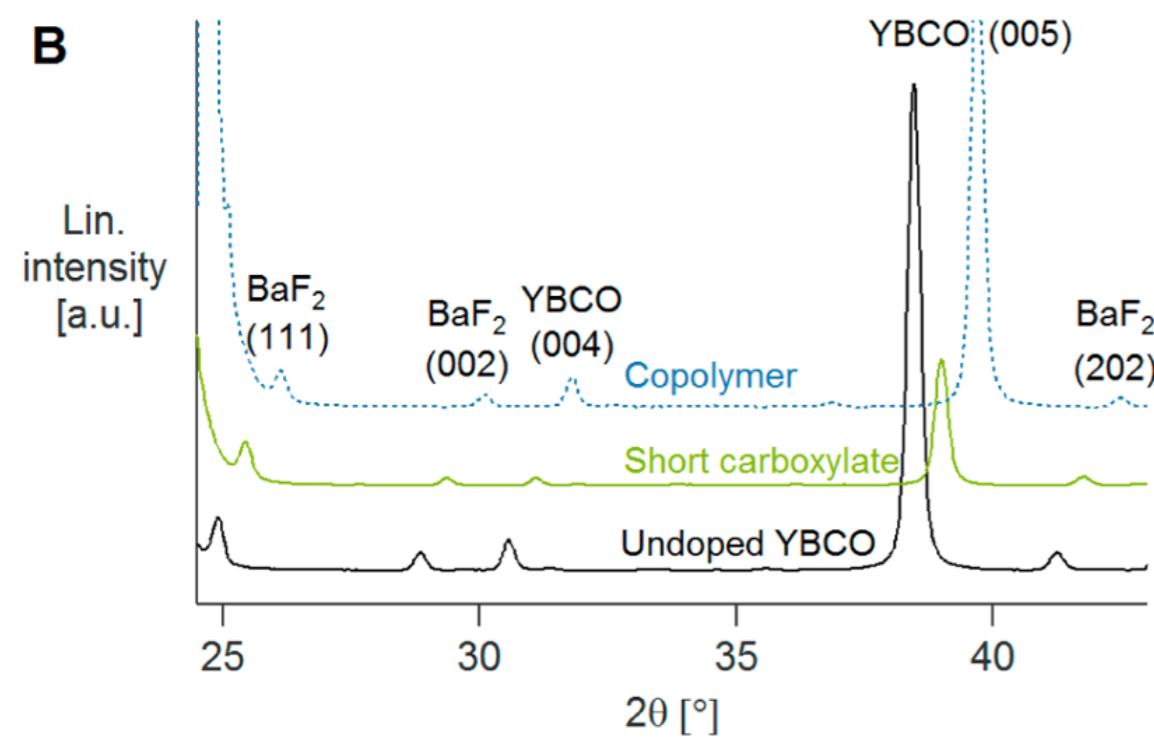
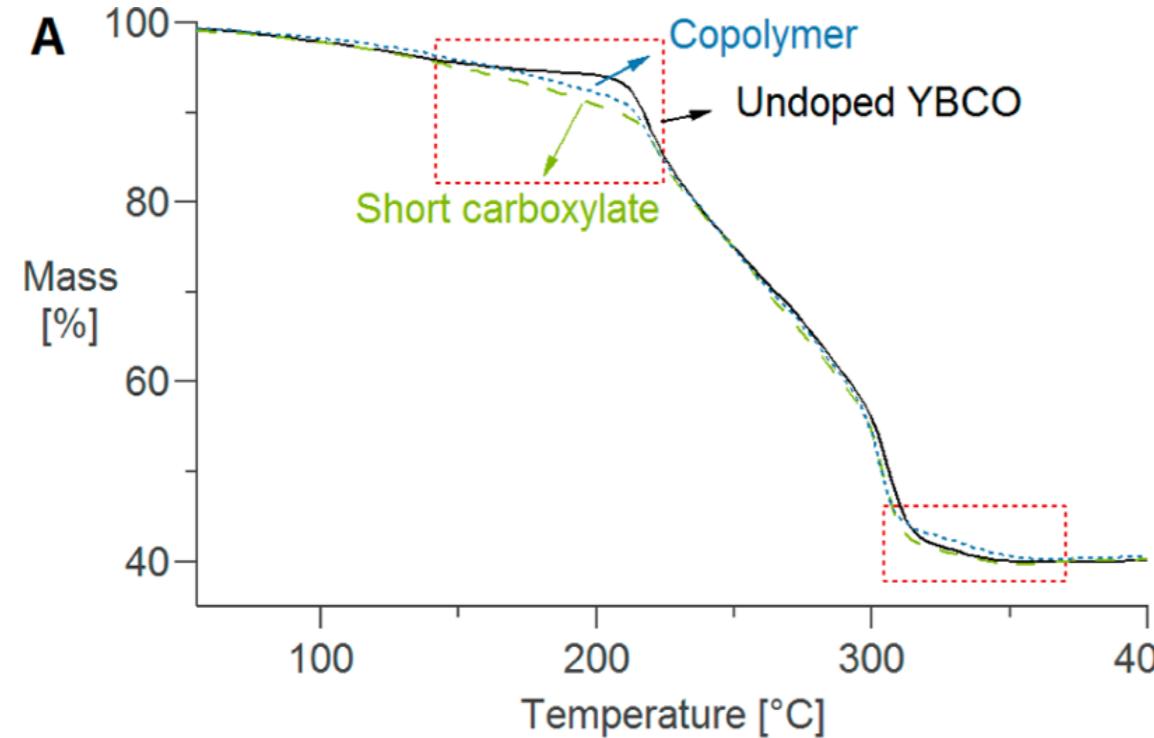
Ligand Exchange/Phase transfer

Via steric dispersant or short carboxylate



H. Rijckaert et al.; Chem. Mater. (2017) 29; 1962

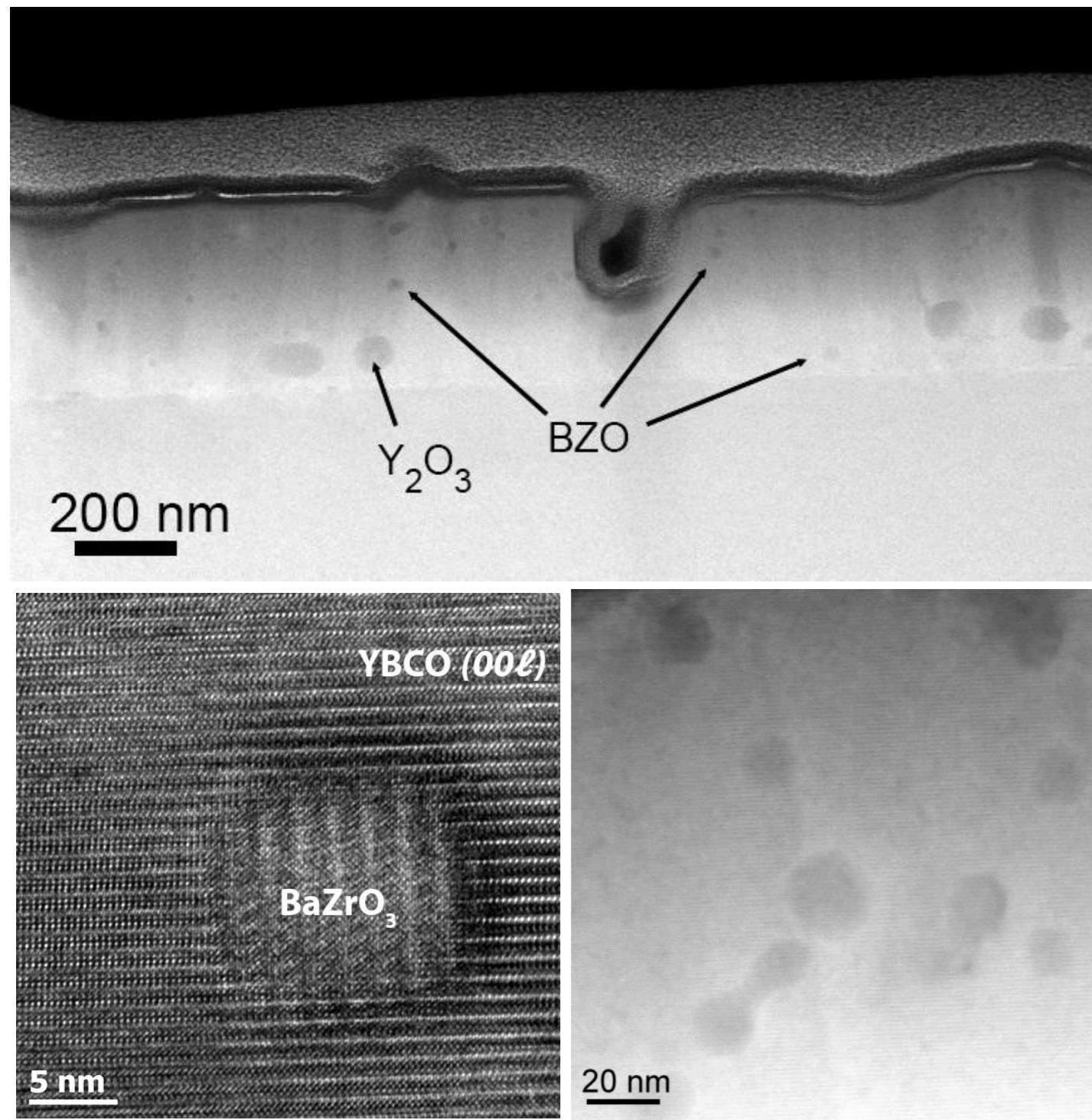
Low-fluorine based nanocomposite



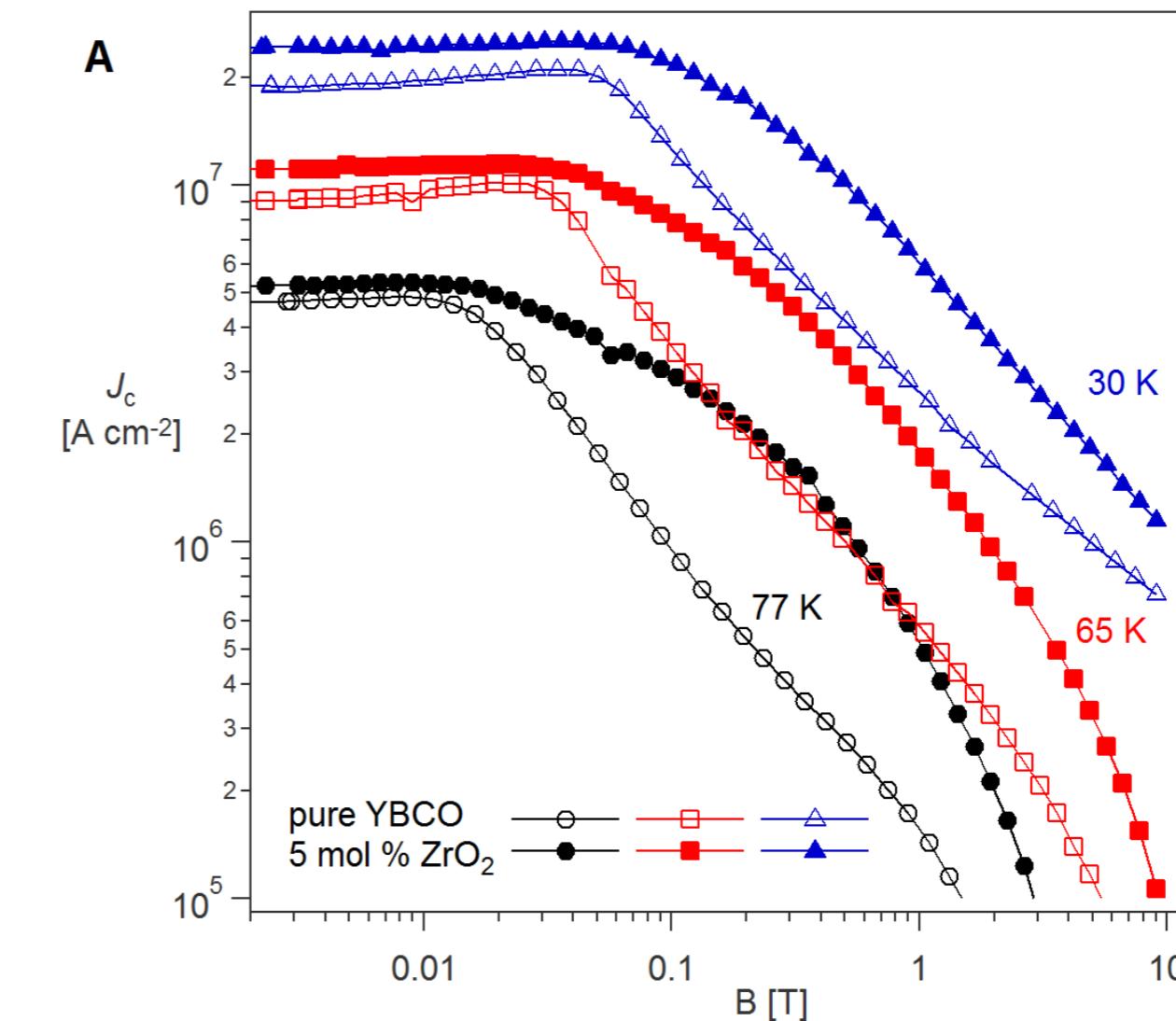
Ligand	d_s nm	Polydispersity index	T_{decomp} °C	$J_{c,\text{sf}} (77 \text{ K})$ MA cm ⁻²
Copolymer	6.4	0.32	340	5.1
Citric acid	5.8	0.86	250	2.3
Tartaric acid	5.9	0.91	265	1.6

Superconducting properties are depending on the used ligands and the nature of nanocrystals

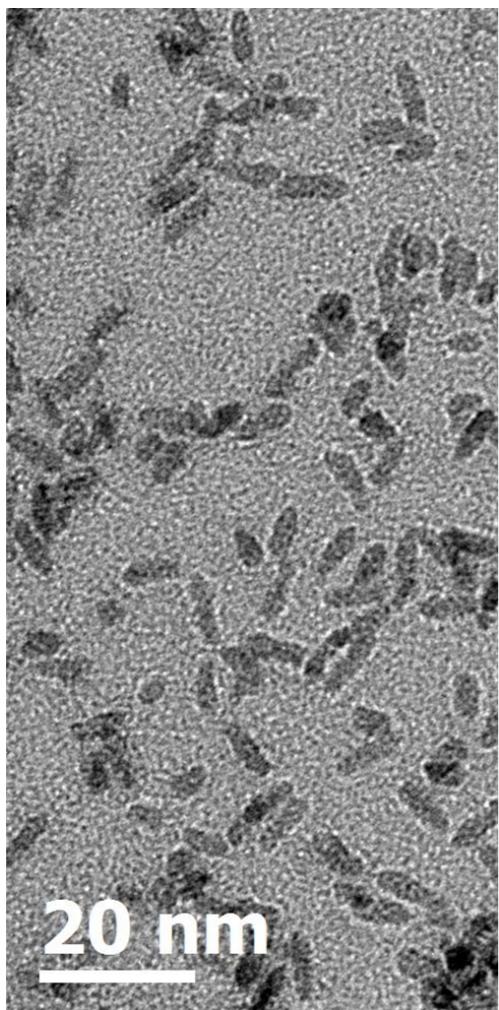
Low-fluorine based nanocomposite



Homogeneous distribution of randomly oriented
10 – 25 nm particles in YBCO layer



Low-fluorine nanocomposite

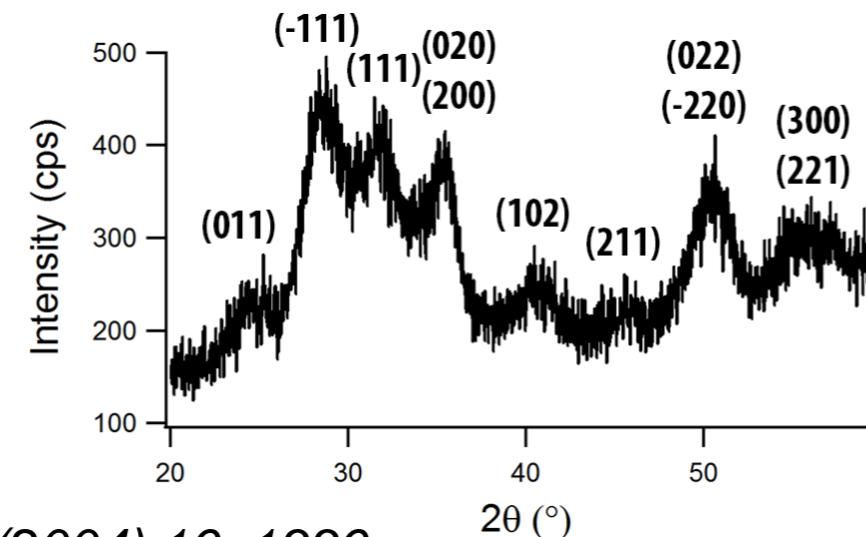


**HfO₂
nanocrystals**

Heating up synthesis

Hf(OC₃H₇)₄, HfCl₄ and TOPO
360 °C – 2h

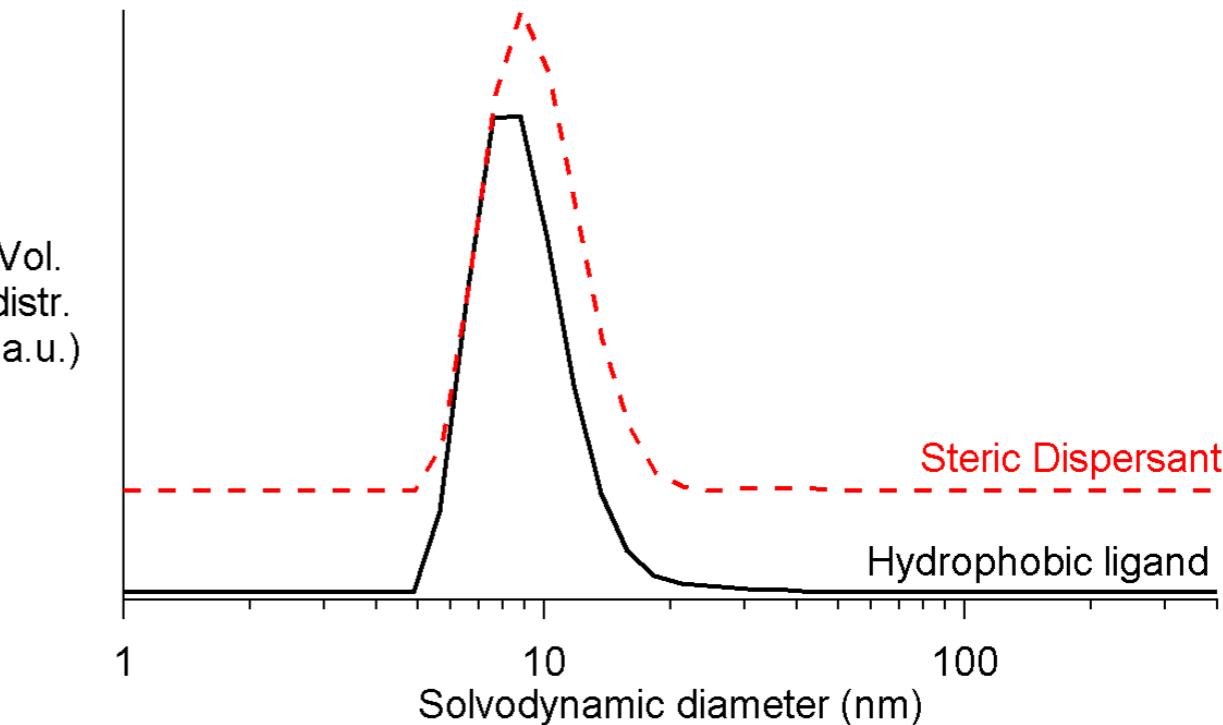
TEM = 2.3-8.0 nm
DLS = 10.2 nm
Scherrer = 3.5 nm
Phase = monoclinic
Rietveld = 70%



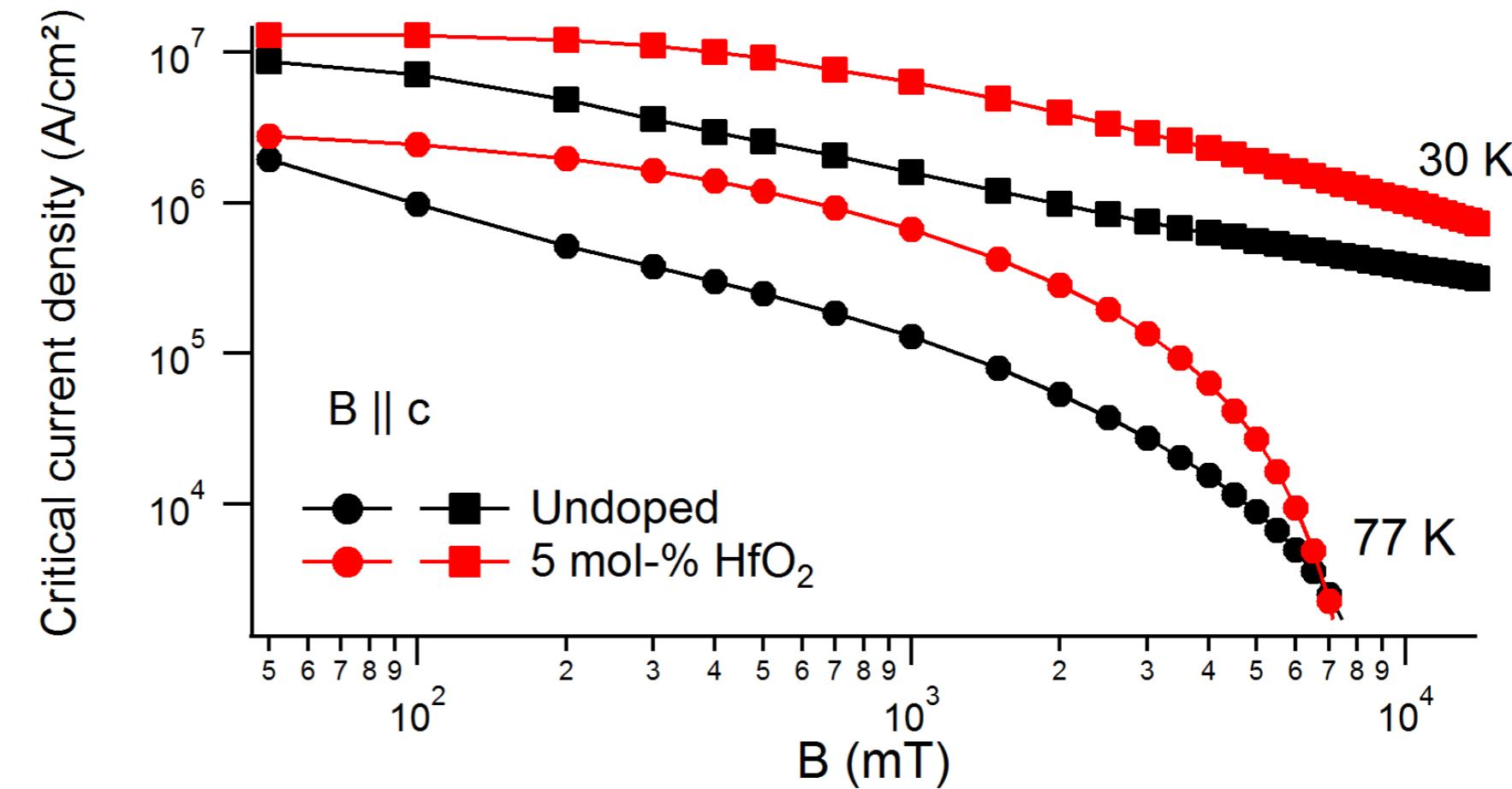
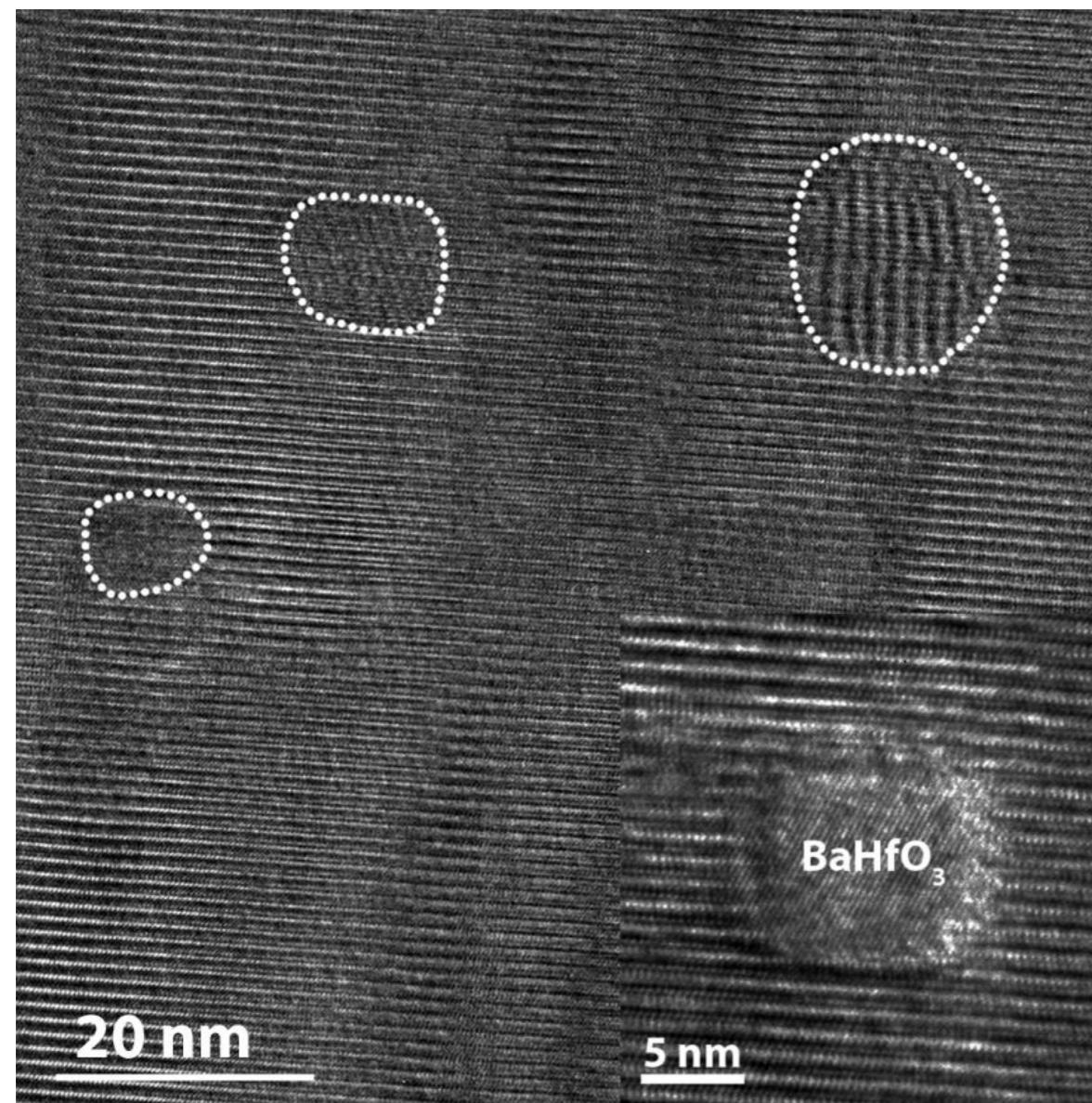
J. Tang et al., Chem. Mater. (2004) 16, 1336

Ligand Exchange/Phase transfer

Via steric dispersant



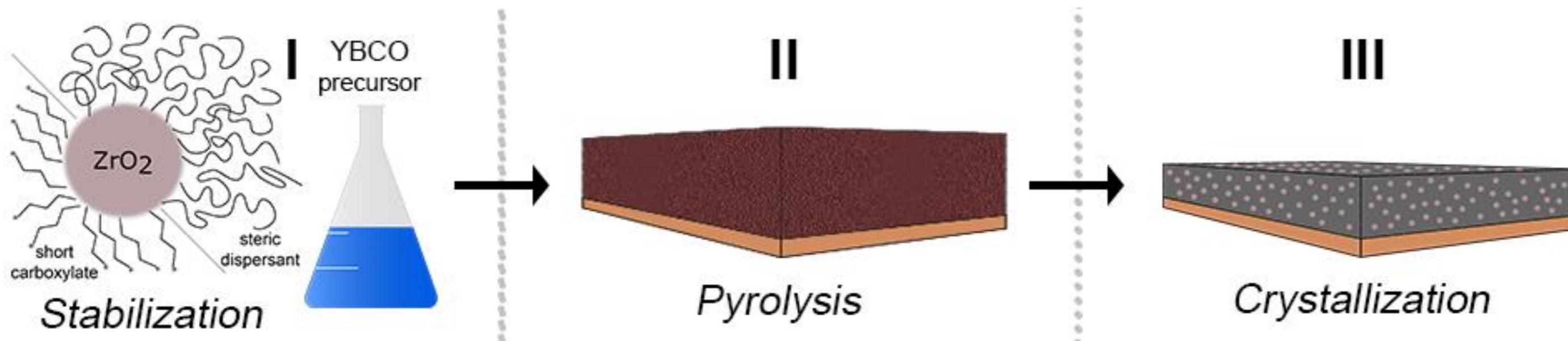
Low-fluorine based nanocomposite



**Homogeneous distribution of randomly oriented
8 – 20 nm particles in YBCO layer**

CONCLUSION

Conclusion



- Chemical solution deposition methods
- Pré-synthesized nanocrystals
- Importance of ligands
- Introduction in both TFA-based as low fluorine YBCO precursors
- Epitaxial YBCO films with improved $J_c(H)$ decay

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Dresden

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